

Form PTO 1449 (Modified)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY DOCKET NO. 292134US26PCT	SERIAL NO. 10/581,601	
LIST OF REFERENCES CITED BY APPLICANT				APPLICANT Masaru SASAKI, et al.		
				FILING DATE June 5, 2006	GROUP 2812	
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EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE
/S.J.N./ AA	6,319,842 B1	11/20/2001	Mukul KHOSLA, et al.			
/S.J.N./ AB	6,107,192	8/22/2000	Suchitra SUBRAHMANIYAN, et al.			
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/S.J.N./ AO	EP 1 081 750 A2	3/7/2001	Europe (corresponds to previously filed JP 2001-203194)	YES	NO	
/S.J.N./ AP	WO 01/29879 A2	4/26/2001	WIPO			
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/S.J.N./ AW	Gi-Chung KWON, et al., "New Plasma Source Development Using a Parallel Resonance Antenna for Dry Etching", IEEE International Conference on Plasma Science, vol. CONF. 30, June 2, 2003, XP010658995, page 403					
AX						
AY						
AZ					<input type="checkbox"/> Additional References sheet(s) attached	
Examiner	Seahvosh Nikmanesh/				Date Considered 06/03/2009	
* Examiner: Initial if reference is considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.						